

The C-flat™ Advantage

C-flat[™] leads to better data sets.

Made with patent pending technology, C-flat[™] provides an ultra-flat surface that results in better particle dispersion and more uniform ice thickness. Patterning is done using deep-UV projection lithography, ensuring the most accurate and consistent hole shapes and sizes down to submicron features. The precise methods by which C-flat[™] is manufactured eliminate artifacts such as excess carbon and edges around holes.

C-flat[™] is affordable

C-flat[™] is available in 25, 50, and 100 packs at a per-grid price less than competing products.

Applications

C-flat holey carbon grids provide the ideal specimen support to achieve high resolution data in cryoTEM making C-flat the perfect choice for:

- Single particle analysis
- Cryo electron tomography
- Automated TEM analysis

...EMS has it!

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Electron Microscopy Sciences

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the premier holey carbon grid for cryo-transmission electron microscopy

C-FLAT™

Holey Carbon and Gold Grids for Cryo-TEM

C-Flat[™] is a clean, ultra-flat holey carbon film TEM grid primarily used for Cryo TEM and Automated TEM. With a variety of available hole diameters, mesh size, film thicknesses, and mesh material, there is a C-Flat[™] product suitable for any application in the TEM.



Frozen-hydrated Bacteriophage Capsid (data acquired on CF-1.2/1.4-4C).

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Consistent

Researchers around the world have reported that the ultra-flat surface of C-flat[™] leads to even ice thickness and uniform particle distribution, allowing for superior 3-D reconstructions. 2 µm hole sizes are standard, but various hole sizes are available to accommodate different particle sizes and magnifications.

Compatible

Clean

carbon film.

C-flat[™] provides a regular array of analysis sites compatible with automated data collection software such as Leginon. This compatibility, in combination with the more uniform ice thickness and particle distribution reported by numerous researchers, results in more high-quality target sites per grid.

C-Flat[™] uses no plastics or polymers in its

production. This means C-Flat[™] is shipped

requires no solvent washing steps prior to

use, leading to less breakage of the holey

clean, so it's ready to use out of the box and



monded Dreduct Line

University Pre

Expanded Product Line The breadth of applications in cryoTEM necessitate a wide range of holey carbon film patterns. And now, with the recent expansion of the product line, a C-flat[™] holey carbon film is available for almost any application. Whether 600nm holes are needed for very high magnifications with ultra-high resolution cameras or large open areas are needed for larger specimens, C-flat[™] is the perfect holey carbon grid.

Microscopyand Microanalysis

An International Journal for the Biological and Physical Sciences

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e-mail: thejimjim@me.com	4210 Sliver Fill Rd., Sulland, MD 20746	
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Heide Schatten	CAMECA	
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Columbia MO 65211	Madison, WI 53711	Cynthia Goldsmith
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e-mail: r.marceau@deakin.edu.au

e-mail: celio001@umn.edu

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Office of Publication

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On th ning e transversal section of Pinus sylvestris after attack by fungus Coniophora puteana, showing abundant hyphae in the resin canals and alteration of axial tracheid walls in both latewood and earlywood. Image © The Trustees of the British Museum.

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